

	Hit \$	Search Text	DBs
24	5	((microstructure or microlens\$4 or (len\$3 near6 array) or feature or structure or pattern or recess\$3 or projection or protuberanc\$4) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (drum or (cylind\$5 near9 platform\$3) or roll\$4) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4) same scanning) and ((translat\$4 or rotat\$4 or spin\$4 or mov\$4) same (cylindric\$4 or drum or platen or roll) same (light\$4 or source or radiation or UV)) and ((substrate or medium or wafer or web) same (foot or feet or inch\$4)) and ((expos\$4 or irradiat\$4 or cur\$4 or illuminat\$4) near22 (time or hour or minute or second))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
25	23	((microstructure or microlens\$4 or (len\$3 near6 array) or feature or structure or pattern or recess\$3 or projection or protuberanc\$4) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (drum or (cylind\$5 near9 platform\$3) or roll\$4 or convey\$4) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and microlens\$3 and ((raster\$4 or scan\$4) same (light or UV or expos\$4 or irradiation))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
26	3	((microlens\$4 or (len\$3 near6 array)) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (drum or (cylind\$5 near9 platform\$3) or roll\$4 or convey\$4) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and (optical near16 (disks or microstructure))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
27	26	((microlens\$4 or (len\$3 near6 array)) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and (optical near16 (disks or microstructure))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
28	55	((microlens\$4 or (len\$3 near6 array)) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin\$4 or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and (optical near16 (structure or disks or microstructure))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
29	29	S30 NOT S29	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
30	87	((microlens\$4 or (len\$3 near6 array)) same (web or (flexible near12 (medium or substrate)) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2)) and ((resin\$4 or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and (optical near16 (structure or disks or microstructure or device)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
31	32	S32 not S30	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
32	17	((microlens\$4 or (len\$3 near6 array) or (micro near2 lens\$2)) same (web or (flexible near12 (medium or substrate) or substrate) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2) same (optical near16 (structure or disks or microstructure or device))) and ((resin\$4 or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4)) and ((web or convey\$3 or drum) same (substrate or wafer or workpiece)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
33	264	((microlens\$4 or (len\$3 near6 array) or (micro near2 lens\$2)) same (web or (flexible near12 (medium or substrate) or substrate) or (plastic near5 substrate) or (polymer\$4 near9 substrate)) same (resin or resist or (radiation near5 sensitive) or photoresist or photosensitive or photocur\$4 or SU\$2) same (optical near16 (structure or disks or microstructure or device))) and ((resin\$4 or resist or photoresist or photocur\$4 or photosensitive) same (expos\$4 or irradiat\$4 or illuminat\$4 or cur\$4))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB